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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PRIORITY Application Serial No. 09/507,193
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Inventor Mark Fischer et al.
Assignee Micron Technology, Inc.
PRIORITY Group Art Unit 1765
PRIORITY Examiner D. Deo
Attorney's Docket No. MI22-1777
Title: Semiconductor Processing Methods of Forming a Conductive
Projection and Methods of Increasing Alignment Tolerances

**Preliminary Amendment to Accompany the filing of a Continuation
Application Under 37 C.F.R. 1.53(b)**

To: Patent Application
Assistant Commissioner for Patents
Washington, D.C. 20231

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Sir:

This is a preliminary amendment accompanying a Request for Continuation Application for the above-entitled patent application. Prior to examining the application, please enter the amendments and consider the remarks contained herein.